

Supporting Information

Theoretical Study on the Water-Assisted Reaction of NCO with HCHO

Benni Du, Weichao Zhang*

College of Chemistry and Chemical Engineering and Jiangsu Key Laboratory of Green Synthetic

Chemistry for Functional Materials, Jiangsu Normal University, Xuzhou, Jiangsu 221116,

People's Republic of China

* Corresponding author. Fax: +86-516-83403164.

E-mail address: zwc@jsnu.edu.cn

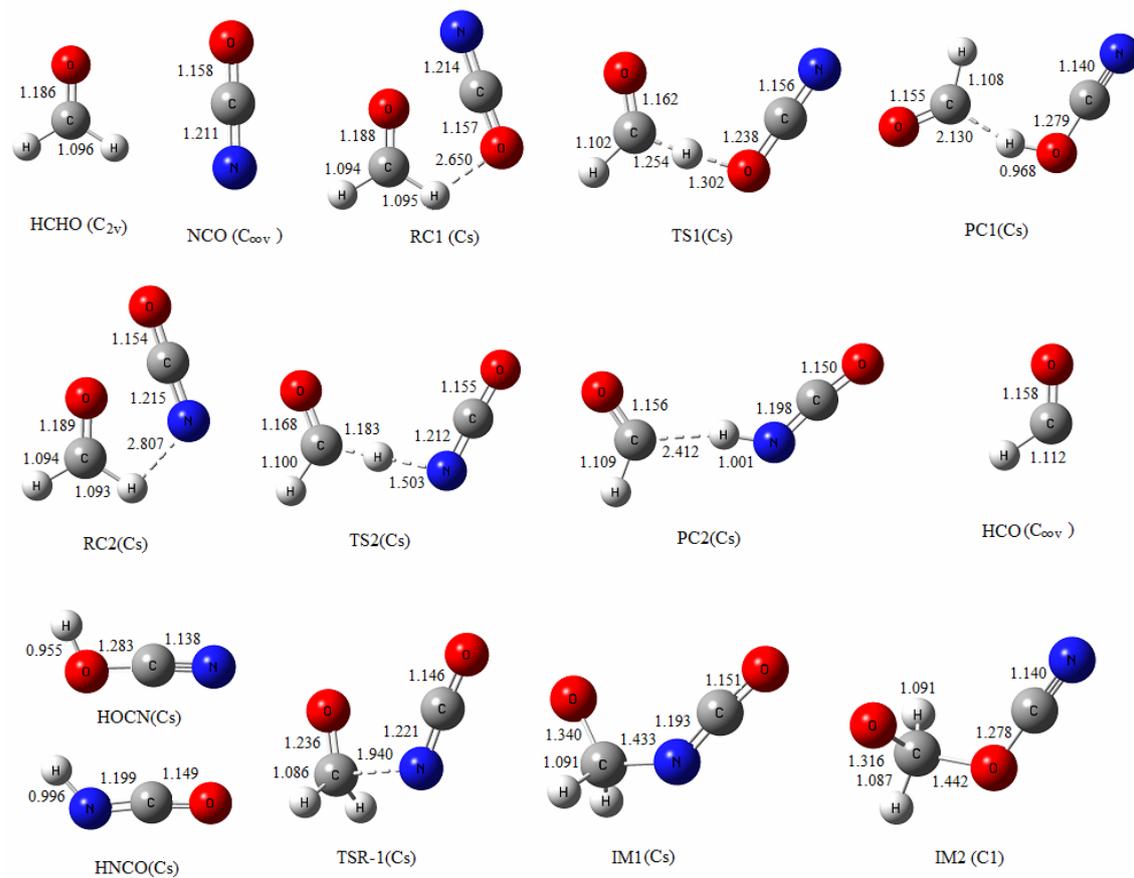


Figure. S1 Optimized geometries for reactants, reactant complexes, intermediates, transition states, product complexes and products involved in the H abstraction and addition reactions of NCO+HCHO without water at the BH&HLYP/6-311++G(3df,3pd) level. Bond lengths are given in angstrom.

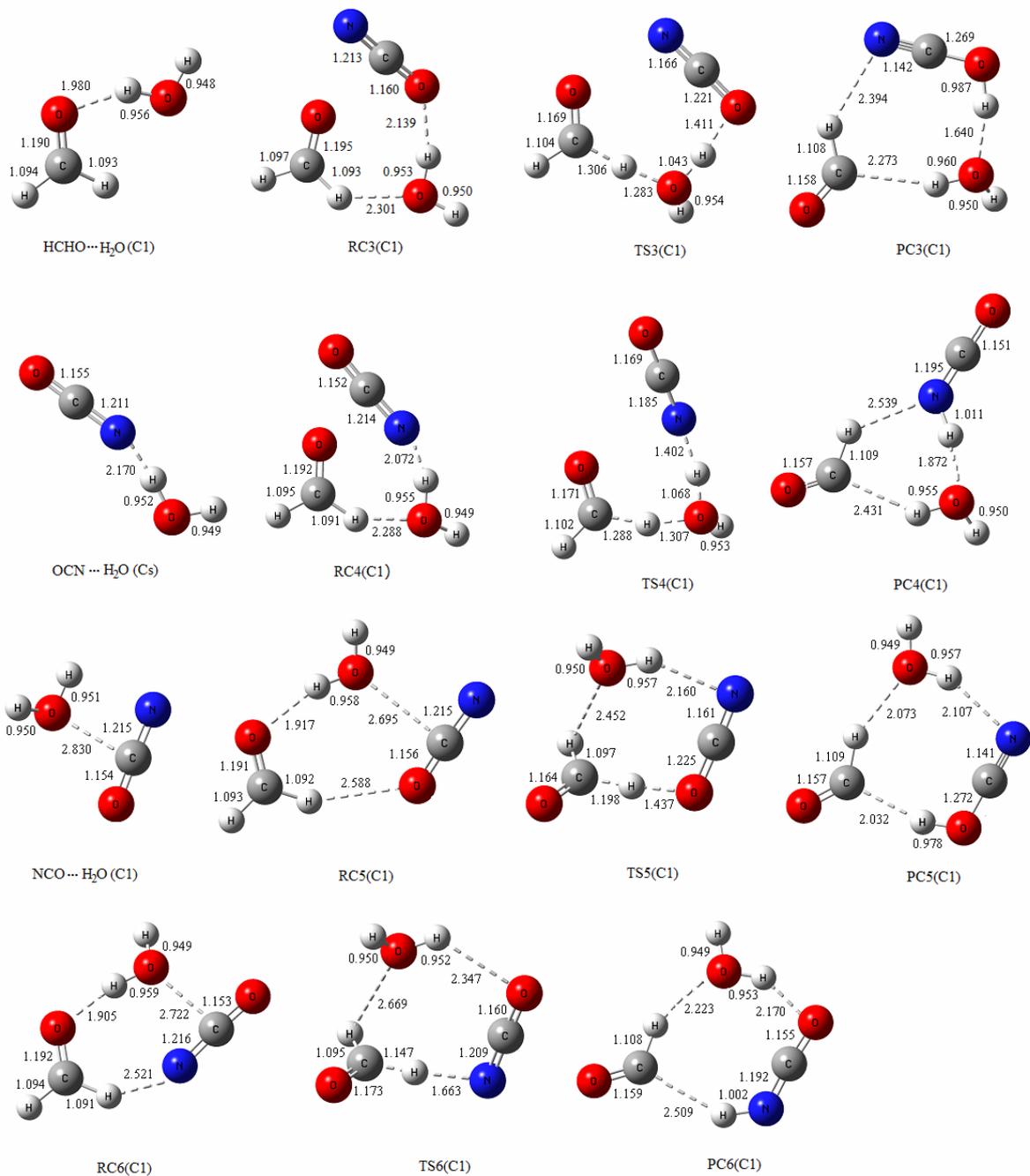


Figure. S2 Optimized geometries for reactant complexes, transition states, product complexes and products involved in the H abstraction reactions of NCO+HCHO with water at the BH&HLYP/6-311++G(3df,3pd) level. Bond lengths are given in angstrom.

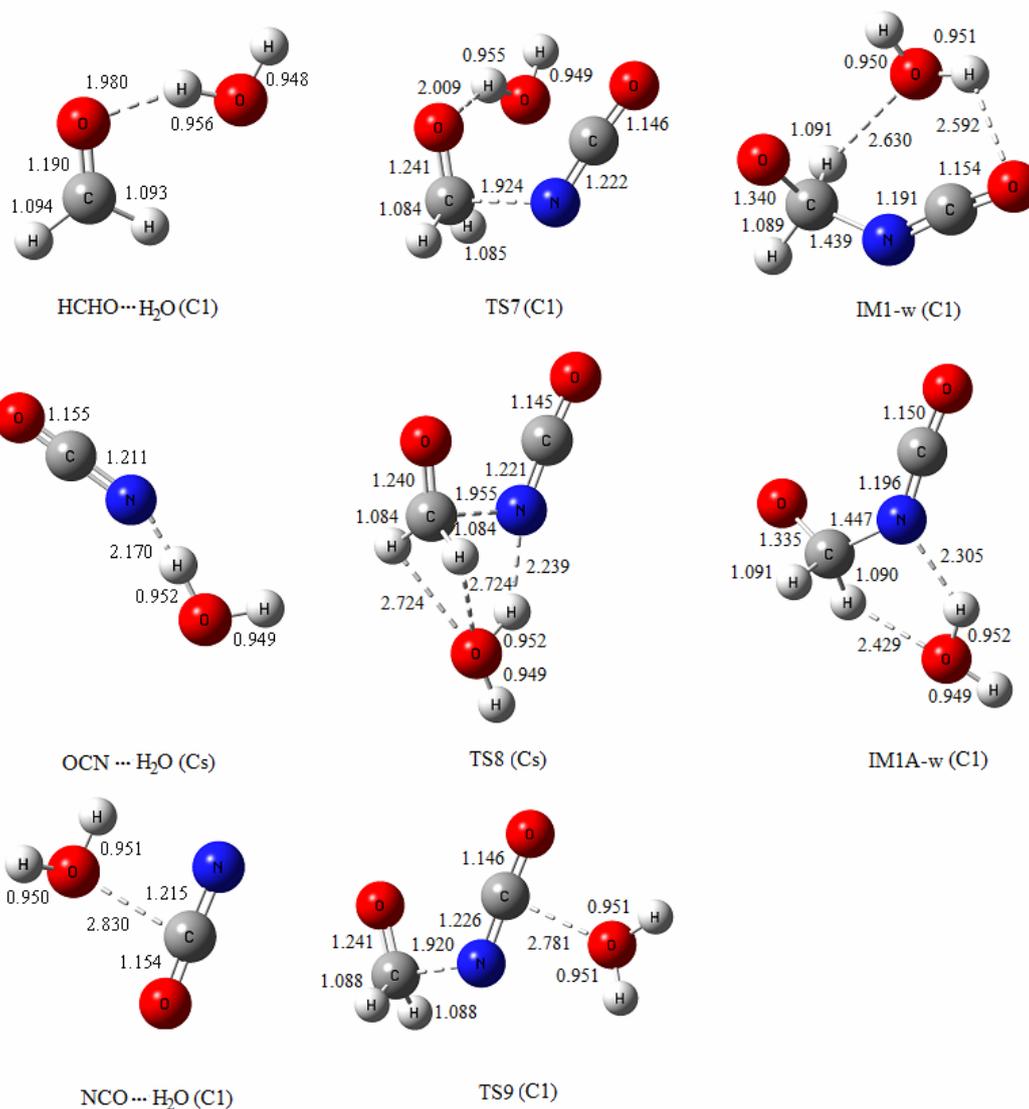


Figure. S3 Optimized geometries for intermediates and transition states involved in the addition reactions of NCO+HCHO with water at the BH&HLYP/6-311++G(3df,3pd) level. Bond lengths are given in Angstrom.

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